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June 26, 2003
Marx, Ryan E.
1713
William K. Chueng
58189US002

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	1		Document Number	Bublication Base		(This field is not required	
Exam. Init."	CI) [(A	oc. Number-(Kind Code if Known) add Kind Code after patent No. when available)	Publication Date or tasue Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevan Figures Appear	
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